S62	3	("4310236").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2003/01/08 13:44
S63	507	(400/625.ccls.) and @ad<"20010801"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/30 16:10
S64	1261	(400/624,578.ccls.) and @ad<"20010801"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/27 16:30
S65	956	(400/636,271,226.ccls.) and @ad<"20010801"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/27 16:31
S66	101	S63 and (substrate material $5film coat$3 layer sheet pad wafer film lamina level plane paper sheet web medium media) with (back$1lash return$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/28 08:35
S67	171	S64 and (substrate material $5film coat$3 layer sheet pad wafer film lamina level plane paper sheet web medium media) with (back$1lash return$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/27 16:36

S68	125	S65 and (substrate material $5film coat$3. layer sheet pad wafer film lamina level plane paper sheet web medium media) with (back$1lash return$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/27 16:36
S69	5	S63 and (substrate material $5film coat$3 layer sheet pad wafer film lamina level plane paper sheet web medium media) with back$1lash	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/27 16:36
S70	10	S64 and (substrate material $5film coat$3 layer sheet pad wafer film lamina level plane paper sheet web medium media) with back$1lash	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/27 16:43
S71	19	S65 and (substrate material $5film coat$3 layer sheet pad wafer film lamina level plane paper sheet web medium media) with back$1lash	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/27 16:49
S72	56	(back$1lash return$3) adj (reduc$5 demot$5 decreas$5) adj (assembly unit system device apparatus machine mechanism section station means module set instrument tool circuit equipment cell appliance structure) and @ad<"20010801"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/28 12:43
S73	7	S72 and (convey$4 feed$4 advanc$4 transfer$4 deliver$4 rotat$4 roll$4) same (media medium paper sheet substrate material $5film coat$3 layer pad wafer lamina level plane web) same (position location region zone co$1ordinat$5 segment section part portion)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/28 09:52

S74	2	S72 and (convey$4 feed$4 advanc$4 transfer$4 deliver$4 rotat$4 roll$4) with ((final second target pre$1select$3 pre$1determin$3 pre$1defin$3 specif$5 pre$1set$4) adj2 (position location region zone co$1ordinat$5 segment section part portion))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/28 09:47
S75	414	(back$1lash return$3) adj (reduc$5 demot$5 decreas$5 prevent$5 eliminat$5 avoid$5) adj (assembly unit system device apparatus machine mechanism section station means module set instrument tool circuit equipment cell appliance structure) and @ad<"20010801"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/28 09:33
S76	36	S75 and (convey$4 feed$4 advanc$4 transfer$4 deliver$4 rotat$4 roll$4) with ((final second target pre$1select$3 pre$1determin$3 pre$1defin$3 specif$5 pre$1set$4) adj2 (position location region zone co$1ordinat$5 segment section part portion))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/28 09:49
S77	36	S75 and (convey$4 feed$4 advanc$4 transfer$4 deliver$4 rotat$4 roll$4) with ((final second target pre$1select$3 pre$1determin$3 pre$1defin$3 specif$5 pre$1set$4 desir$5 intend$3) adj2 (position location region zone co$1ordinat$5 segment section part portion))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/28 09:53
S78	1217033	(convey$4 feed$4 advanc$4 transfer$4 deliver$4 rotat$4 roll$4) near3 (media medium paper sheet substrate material $5film coat$3 layer pad wafer lamina level plane web) and @ad<"20010801"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/28 09:57
S79	263211	S78 and (stop$5 ceas$5 end$3 halt$5 hold$3 paus$3) near3 (media medium paper sheet substrate material $5film coat$3 layer pad wafer lamina level plane web)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/28 10:16

S80	45172	S79 and (media medium paper sheet substrate material $5film coat$3 layer pad wafer lamina level plane web) with ((final second target pre$1select$3 pre$1determin$3 pre$1defin$3 specif$5 pre$1set$4) adj2 (position location region zone co$1ordinat$5 segment section part portion))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/28 10:36
S81	26915	S80 and (media medium paper sheet substrate material $5film coat$3 layer pad wafer lamina level plane web) near3 ((final second target pre$1select$3 pre$1determin$3 pre$1defin$3 specif$5 pre$1set$4) adj2 (position location region zone co$1ordinat$5 segment section part portion))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/28 10:26
S82	956	S81 and (reduc$5 demot$5 decreas$5 prevent$5 eliminat$5 avoid$5 $2adjust$ regulat$3 control$3 calibrat$5) near2 (back$1lash return$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/28 10:31
S83	83	S82 and short near3 (position location region zone co$1ordinat$5 segment section part portion)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/28 10:39
S84	0	S83 and back$1lash adj (reduc$5 demot$5 decreas$5)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/28 13:09
S85	2	S83 and back$1lash adj (reduc$5 demot$5 decreas$5 prevent$5 eliminat$5 avoid$5 $2adjust$ regulat$3 control$4 calibrat$5)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/30 16:19

S86	2	("5961224").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/28 16:20
S87	12	((back$1lash and (reduc$5 demot$5 decreas$5 prevent$5 eliminat$5 avoid$5 $2adjust$ regulat$3 control$4 calibrat$5) and short and (position location region zone co$1ordinat$5 segment section part portion) and (media medium paper sheet substrate material $5film coat$3 layer pad wafer lamina level plane web) and (final second target pre$1select$3 pre$1determin$3 pre$1defin$3 specif$5 pre$1set$4) and (convey$4 feed$4 advanc$4 transfer$4 deliver$4 rotat$4 roll$4)).clm.) and @ad<"20010801"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/30 15:56
S88	1363	(400/582,593,608.4.ccls.) and @ad<"20010801"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/30 16:11
S89	1539	(400/621,629,630,637,636.2.ccls.) and @ad<"20010801"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/30 16:15
S90	1569	(271/10.05,227,258.01,270,242.ccls.) and @ad<"20010801"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/30 16:16
S91	1730	(101/116,118,216,226,232.ccls.) and @ad<"20010801"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/30 16:17

S92	7	S88 and back$1lash near3 (reduc$5 demot$5 decreas$5 prevent$5 eliminat$5 avoid$5 $2adjust$ regulat$3 control$4 calibrat$5)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/09/30 16:26
S93	6	S89 and back$1lash near3 (reduc$5 demot$5 decreas$5 prevent$5 eliminat$5 avoid$5 $2adjust$ regulat$3 control$4 calibrat$5)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/09/30 16:33
S94	8	S90 and back$1lash near3 (reduc$5 demot$5 decreas$5 prevent$5 eliminat$5 avoid$5 $2adjust$ regulat$3 control$4 calibrat$5)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/09/30 16:34